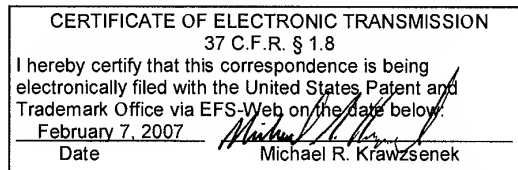


PATENT

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Title: HIGH INDEX AND HIGH IMPACT RESISTANT  
POLYTHIOURETHANE/UREA MATERIAL, METHOD OF  
MANUFACTURING SAME AND ITS USE IN THE OPTICAL FIELD

Appl. No.: 09/992,054  
Applicants: Adileh *et al.*  
Filed: November 14, 2001  
TC/A.U.: 1711  
Examiner: Sergeant, Rabon A  
Docket No.: ESSR:058US  
Customer No.: 32425  
Confirmation No. 4850



**RESPONSE TO THE OFFICE ACTION MAILED ON NOVEMBER 8, 2006**

**MAIL STOP AMENDMENT**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Applicant submits this Response to the Office Action mailed on November 8, 2006 ("the Action"), for the above-referenced case. It is believed that no fee is due for filing this Response. Should any fees under 37 C.F.R. §§ 1.16 to 1.21 be required for any reason relating to this document, the Commissioner is authorized to deduct said fees from or to Fulbright & Jaworski Deposit Account No. 50-1212/ESSR:058US.

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2.

**Remarks/Arguments** begin on page 9.